Receipt date: 03/16/2009

OK TO ENTER: /M.L.P./

03/22/2009

RESPONSE UNDER 37 C.F.R. §1.116 EXPEDITED PROCEDURE EXAMINING GROUP 1792

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kwang Choe et al. Examiner: Padgett, Marianne L.

Serial No.: 10/674,648 Art Unit: 1792

Filed: September 30, 2003 Docket No.: YOR920030294US1 (16817)

Title: SOI BY OXIDATION OF POROUS SILICON

Date: March 16, 2009

Confirmation No.: 4794

Commissioner for Patents P.O. Box 1450 Alexandria, VA. 22313

## RESPONSE UNDER 37 C.F.R. § 1.116

Sir:

In response to the Final Office Action dated January 16, 2009, Applicants respectfully request that the following amendments and remarks be entered as a matter of record in the above-identified application. Also included herein is an Examiner Interview Summary of the phone interview between Examiner Marianne L. Padgett and Applicants' representative held on March 16, 2009.

## CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on March 16, 2009.

Dated: March 16, 2009

Harry A. Hild Jr